

PATENT

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Appl. No.:	10/808,692	Confirmation No.:	6062
Applicant(s):	Ogihara et al.		
Filed:	03/25/2004		
Art Unit:	2891		
Examiner:	A. Sarkar		
Title:	COMPOSITION FOR FORMING POROUS FILM, POROUS FILM AND METHOD FOR FORMING THE SAME, INTERLEVEL INSULATOR FILM AND SEMICONDUCTOR DEVICE		

Docket No.: 035576/276101  
Customer No.: 00826

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**REPLY UNDER 37 CFR § 1.121**

Sir:

In response to the Office Action dated September 8, 2006, please consider the following remarks:

**Remarks/Arguments** begin on page 2 of this paper.